

U.S. Department of Commerce, Patent and Trademark Office				Atty Docket No.		Serial No.	
				M-7554-1D US		<del>Unassigned</del>	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Applicant(s)		10/627038	
(Use several sheets if necessary)				Siniaguine et al.			
				Filing Date		Group	
				Herewith		<del>Unassigned</del> 1763	

  

U.S. Patent Documents							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
<i>WJP</i>	AA	3,598,083	10 Aug. 1971	Dort et al.			
<i>WJP</i>	AB	3,853,091	10 Dec. 1974	Christensen et al.			
<i>WJP</i>	AC	4,315,960	2/16/1982	Ohji et al.			
<i>WJP</i>	AD	4,416,760	11/22/1983	Turner			
<i>WJP</i>	AE	4,593,168	3 Jun. 1986	Haruo Amada			
<i>WJP</i>	AF	5,029,555	7/9/1991	Dietrich et al.			
<i>WJP</i>	AG	5,204,145	3/20/1993	Gasworth			
<i>WJP</i>	AH	5,238,532	8/24/1993	Zarowin et al.			
<i>WJP</i>	AI	5,282,921	2/1/1994	Poultney			
<i>WJP</i>	AJ	5,291,415	3/1/1994	Zarowin et al.			
<i>WJP</i>	AK	5,308,461	5/3/1994	Ahonen			

  

Foreign Patent Documents							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
<i>WJP</i>	AL	0 807 964 A1	11/19/1997	EP				
<i>WJP</i>	AM	01 133318	25-May-89	JP				
<i>WJP</i>	AN	3-284839 A	Dec. 1991	JP				
<i>WJP</i>	AO	59-112624 A	Jun. 1984	JP				
<i>WJP</i>	AP	60-24018 A	Feb. 1985	JP				

  

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)		
<i>WJP</i>	AQ	Lieberman, Michael A. et al., "Principles of Plasma Discharges and Materials Processing" (John Wiley & Sons, New York, 1994), p. 1.
<i>WJP</i>	AR	Agrikov et al., "Dynamic Plasma Treatment of HIC (Hybrid Integrated Circuit) Substrates", Elektronnaya Tehnika, Ser, 10, 5(71), 1988, pp. 30-32, with partial translation.
	AS	

  

Examiner <i>Maureen J. O'Connell</i>	Date Considered <i>06/05/2005</i>
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

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<i>WJP</i>	AT	5,312,510	5/17/1994	Poultney				
<i>WJP</i>	AU	5,365,031	11/15/1994	Mumola				
<i>WJP</i>	AV	5,558,909	9/24/1996	Poliquin et al.				
<i>WJP</i>	AW	5,665,167	9/9/1997	Deguchi et al.				
<i>WJP</i>	AX	5,767,627	6/16/1998	Siniaguine				
<i>WJP</i>	AY	5,811,021	9/22/1998	Zarowin et al.				
<i>WJP</i>	AZ	5,834,730	11/10/1998	Suzuki et al.				
<i>WJP</i>	BA	6,105,534	8/22/2000	Siniaguine, et al.				
<i>WJP</i>	BB	6,139,678	10/31/2000	Siniaguine				
<i>WJP</i>	BC	6,287,976	11 Sept. 2001	Siniaguine et al.				
Foreign Patent Documents								
							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
<i>WJP</i>	BD	WO 92/12273	7/23/1992	PCT				
<i>WJP</i>	BE	WO 92/12610	7/23/1992	PCT				
<i>WJP</i>	BF	WO 96/21943	7/18/1996	PCT				
<i>WJP</i>	BG	WO 96/32742	10/17/1996	PCT				
<i>WJP</i>	BH	WO 97/45856	12/4/1997	PCT				
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<i>WJP</i>	BJ	WO 98/19337	5/8/1998	PCT				
<i>WJP</i>	BK	WO 99/16927	8 Apr. 1999	PCT				
<i>WJP</i>	BL	WO 99/26796	6/3/1999	PCT				
<i>WJP</i>	BM	WO 99/46805	16 Sep. 1999	PCT				
	BN							
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	BQ							
Examiner <i>Maureen J. Ameli</i>				Date Considered 06/05/2005				
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